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JEV
PATENT

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Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450

**REVOCATION AND POWER OF ATTORNEY, CHANGE OF
CORRESPONDENCE ADDRESS, APPOINTMENT OF NEW POWER OF
ATTORNEY AND STATEMENT UNDER 37 CFR 3.73(B)**

I hereby revoke all previous powers of attorney given in the applications identified in the attached spreadsheet entitled Exhibit A, Group Art Unit 1700.

I hereby appoint the practitioners at Customer Number **25108** for all patent applications identified in the attached Exhibit A.

CHANGE OF CORRESPONDENCE ADDRESS

Please change the correspondence address for the patent applications on attached Exhibit A to the address associated with Customer Number **25108**.

I am the Assignee of record of the entire interest. See 37 CFR 3.71.

Statement under 37 CFR 3.73(b) is included.



PATENT

STATEMENT UNDER 37 CFR 3.73(b)

Molecular Imprints, Inc., a Delaware Corporation states that it is the Assignee of the entire right, title and interest in the patent applications identified on attached Exhibit A by virtue of:

An assignment from the inventors of each patent application identified on attached Exhibit A to Molecular Imprints, Inc., recorded as shown on attached Exhibit A in the United States Patent and Trademark Office.

The undersigned, whose title is supplied below, is authorized to act on behalf of the assignee.

10-11-04
Date

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Respectfully submitted

Norman E. Schumaker
Norman E. Schumaker, PhD
President and CEO
Molecular Imprints, Inc.



EXHIBIT A
Group Art Unit 1700

Dkt. No	Filed	App. No.	Title	Inventors	GPAU	Examiner	Conf. No.	Assignment Recorded	Reel/ Frame
P26-01-02	May 1, 2002	10/136,188	METHODS OF MANUFACTURING A LITHOGRAPHY TEMPLATE	Ronald D. Voisin	1756	Kathleen Duda	6754	Oct. 16, 2002	013399/0864
P31-05-02	Jul 9, 2002	10/191,749	METHOD FOR DISPENSING LIQUIDS (AS AMENDED)	Michael P. C. Watts et al.	1762	Frederick John Parker	6216	Oct. 17, 2002	013818/0478
P32-06-02	Jul 11, 2002	10/194,411	FORMATION OF DISCONTINUOUS FILMS DURING AN IMPRINT LITHOGRAPHY PROCESS	Byung-Jin Choi et al.	1732	Leo B. Tentoni	9760	Nov. 12, 2003	014680/0214
P33-07-02	Jul 11, 2002	10/194,991	STEP AND REPEAT IMPRINT LITHOGRAPHY PROCESS	Sidgata V. Sreenivasan et al.	1732	Leo B. Tentoni	1599	Oct. 28, 2002	013430/0527
P35-09-02	Jul 11, 2002	10/194,410	METHOD AND SYSTEM FOR IMPRINT LITHOGRAPHY USING AN ELECTRIC FIELD	Sidgata V. Sreenivasan et al.	1765	Binh X. Tran	9761	Dec. 13, 2002	013576/0680
P38-12-02	Aug 1, 2002	10/210,894	ALIGNMENT SYSTEMS FOR IMPRINT LITHOGRAPHY	Sidgata V. Sreenivasan et al.	1722	Emmanuel S. Luk	7883	Oct. 21, 2002	013420/0724
P39-13-02	Aug 1, 2002	10/210,780	ALIGNMENT METHODS FOR IMPRINT LITHOGRAPHY	Sidgata V. Sreenivasan et al.	1756	Christopher G. Young	7348	Oct 21, 2003	013411/0563
P40-14-02	Oct 4, 2002	10/264,926	A METHOD OF FORMING A LAYER ON A SUBSTRATE TO FACILITATE FABRICATION OF METROLOGY STANDARDS	Sidgata V. Sreenivasan and Michael P. C. Watts	1765	Binh X. Tran	6185	Oct. 4, 2002	013762/0642
P41-15-02	Sep 5, 2002	10/235,314	FUNCTIONAL PATTERNING MATERIAL FOR IMPRINT LITHOGRAPHY PROCESSES	Michael P. C. Watts	1732	Mathieu D. Vargot	2254	Sep 5, 2002	013268/0601
P46-18-02	Nov 13, 2002	10/293,223	METHOD OF REDUCING PATTERN DISTORTIONS DURING IMPRINT LITHOGRAPHY PROCESSES	Daniel Irving Rubin	1732	Leo B. Tentoni	5826	Jan 29, 2003	013702/0096
P48-19-02	Oct 4, 2002	10/264,960	A METHOD AND A MOLD TO ARRANGE FEATURES ON A SUBSTRATE TO REPLICATE FEATURES HAVING MINIMAL DIMENSIONAL VARIABILITY	Sidgata V. Sreenivasan and Michael P. C. Watts	1732	Suzanne E. McDowell	5251	Oct 4, 2002	013369/0415
P53-24D26	Nov 13, 2002	10/293,919	METHODS OF INSPECTING A LITHOGRAPHY TEMPLATE	Ronald D. Voisin	1752	Barbara Lee Gillian	7854	Oct. 16, 2002	013399/0864
P56-27-02	Feb 27, 2003	10/375,817	METHOD TO REDUCE ADHESION BETWEEN A POLYMERIZABLE LAYER AND A SUBSTRATE EMPLOYING A FLUORINE-CONTAINING LAYER	Van N. Truskett et al.	1762	Erma C. Cameron	6500	Feb. 27, 2003	013833/0986
P73-15-03	Feb 27, 2003	10/375,832	COMPOSITION AND METHOD TO FORM A RELEASE LAYER	Van N. Truskett et al.	1762	Erma C. Cameron	6512	Feb. 27, 2003	013830/0257
P75-17-03	Oct 16, 2003	10/687,519	LOW SURFACE ENERGY TEMPLATES	Van N. Truskett et al.	1762	(unknown)	5222	Mar. 24, 2004	015123/0209
P76-18-03	Mar 25, 2003	10/396,615	POSITIVE TONE BI-LAYER IMPRINT LITHOGRAPHY METHOD	Sidgata V. Sreenivasan	1763	(unknown)	6079	Mar 25, 2003	013914/0929

EXHIBIT A - pg. 2
Group Art Unit 1700

Dkt. No	Filed	App. No.	Title	Inventors	GPAU	Examiner	Conf. No.	Assignment Recorded	Reel/ Frame
P79-21-03	Apr 25, 2003	10/423,642	A METHOD OF FORMING STEPPED STRUCTURES EMPLOYING IMPRINT LITHOGRAPHY	Sidgata V Sreenivasan	1763	(unknown)	9150	April 25, 2003	014011/ 0766
P86-28-03	Aug 21, 2003	10/645,306	CAPILLARY IMPRINTING TECHNIQUE	Byung-Jin Choi et al.	1763	(unknown)	7847	Dec 22, 2003	014823/ 0606
P100-42-03	Sep 25, 2003	10/670,980	IMPRINT LITHOGRAPHY TEMPLATE HAVING OPAQUE ALIGNMENT MARKS	Sidgata V Sreenivasan and Philip D. Schumaker	1763	(unknown)	8096	Sep 25, 2003	014561/ 0695